IFW/172

PATENT APPLICATION

ITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Makoto IIDA

Group Art Unit: 1722

Application No.:

10/553,754

Docket No.:

125664

Filed: October 18, 2005

SEP 0 7 2006

For:

A METHOD FOR PRODUCING A SINGLE CRYSTAL AND A SINGLE CRYSTAL

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records. A Supplemental Application Data Sheet is attached.

Respectfully submitted,

William P. Berridge Registration No. 30,024

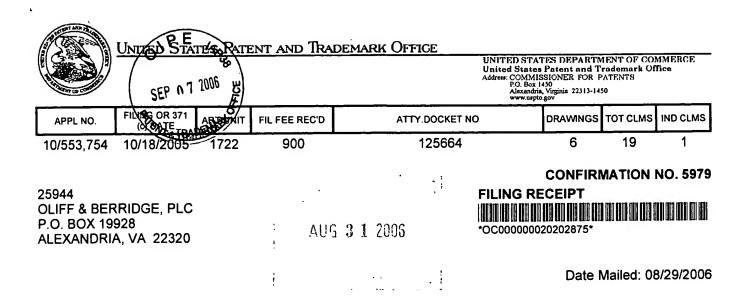
Tarik M. Nabi Registration No. 55,478

WPB:TMN/cdk

Date: September 7, 2006

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Applicant(s)

Makoto lida, Gunma, JAPAN;

Assignment For Published Patent Application

SHIN-ETSU HANDOTAI CO., LTD, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/06003 04/26/2004

Foreign Applications

If Required, Foreign Filing License Granted: 08/25/2006

The country code and number of your priority application, to be used for filing abroad under the Paris

Convention, is US10/553,754

Projected Publication Date: 12/07/2006

Non-Publication Request: No

Early Publication Request: No

Add Foreign Priority
Information
Japan 2003-135085
May 13, 2003

Title

Method for producing single crystal and single crystal

Preliminary Class

117

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